**International Conference on Ultrahigh Intensity Lasers-2008** 

Generation of 700TW femtosecond Ti:sapphire laser by optimizing the efficiency in a CPA facility with three amplifier stages

Zhaohua Wang<sup>1</sup>, Zhiyi Wei<sup>1</sup>\*, Jiangfeng Zhu<sup>1</sup>, Peng Wang<sup>1</sup>, Qiang Du<sup>1</sup>, Cheng Liu<sup>1</sup>, Hao Teng<sup>1</sup>, Jinglong Ma<sup>1</sup>, Yutong Li<sup>1</sup>, Liming Chen<sup>1</sup> and Jie Zhang<sup>1,2</sup>

 Laboratory of Optical Physics, Institute of Physics, Chinese Academy of Sciences (CAS), Beijing China, 100190
Shanghai JiaoTong University, Shanghai China, 200240

Oct 27-31,2008, Shanghai-Tongli, China

## Outline

### Background

- General design and front stages
- 100J glass pump laser at 527nm
- Main amplifier and compressor
- Conclusion and Prospect



# Some multi-100TW laser facilities in the world

Facility	Peak Power	Туре	Pulse duration	Pulse Energy
RAL, UK	1PW	Nd:glass/OPCPA	600fs	600J
ILE, Japan	700TW	Nd:glass/OPCPA	700fs	350J
JAERI, Japan	850TW	Ti:sapphire	33fs	28J
MBI, Germany	100TW	Ti:sapphire	50fs	5J
Phelix, Germany	1PW	Ti:s/Nd:glass	500 fs	500 J
LLNL, USA	200TW	Ti:sapphire	100fs	20Ј
LULI, France	100TW	Nd:glass	300fs	30J
CEDEX, France	100TW	Ti:sapphire	25fs	2.5J
SILEX-I (四川)	286TW	Ti:sapphire	30fs	8.7J
XL-III(北京)	355TW	Ti:sapphire	31fs	11J
QG-III (上海)	890TW	Ti:sapphire	34fs	<b>30J</b>

#### High-power laser facilities in China



### Development of laser systems in IOP



**XL-I laser system** 



#### XL-II laser system



#### **XL-III laser system**







**350 TW** 

(2006)

1.4 TW (1999)

**20 TW** (2001)



### General design of 700TW laser



### Femtosecond Ti:sapphire Oscillator

#### **Specifications:**

Stability: <±1% Average power: >500mW(>1W) Pulse duration: ~ 20fs Peak power: >0.3MW(>1MW) Tunable range: 740~860nm Repetition rate: ~100MHz





### Pulse duration and spectrum



### **Doubled trip stretcher**



### Pulse duration after stretcher









### Second stage amplifier



With 2.6J pump laser energy, amplified laser of 780mJ was obtained, corresponding to the efficiency of 27%





### Layout of 100J pump laser









Pumped the final amplifier with 120J laser at 527nm, laser energy only 43.5J was obtained.





#### Vacuum compressor





### compressed pulse autocorrelation



# Outline

### Conclusions and Prospect

0

### Conclusions

◆We designed and established a CPA laser facility which is capable of multi-100TW peak power with three stage amplifiers.

◆With the pump energy of 120J, amplified laser energy of 43.5J was obtained. After the compressor, the pulse energy was up to 22.5J and the pulse duration was as short as 31fs, which corresponds to peak power of 725TW.



◆A new high contrast ratio amplifier and OPCPA amplifier will be used for improving the contrast ratio in front stages.



**Poster Section I: 17 Changwen Xu,** "Improvement of output energy in OPCPA based on Ti:sapphire laser by the gain distribution among the nonlinear crystals"



With those improved techniques, we expect to generate laser pulses with contrast ratio of about 10<sup>10</sup>

### **Thank You for your attention!**